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PATENT  
790001-2002

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

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IDS  
7-23-03  
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Applicants : Yoshitaka TSUNASHIMA et al.  
U.S. Serial No. : 09/803,265  
Filing Date : March 9, 2001  
For : **SEMICONDUCTOR DEVICE HAVING A GATE  
INSULATING FILM STRUCTURE INCLUDING AN  
INSULATING FILM CONTAINING METAL, SILICON AND  
OXYGEN AND MANUFACTURING METHOD THEREOF**  
Examiner: : Jennifer M. Dolan  
Group Art Unit : 2813

745 Fifth Avenue  
New York, New York 10151

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Date of Deposit: July 9, 2003

I hereby certify that this paper or fee is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" Service under 37 CFR 1.10 on the date indicated above and is addressed to: **Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.**

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**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Further to the Information Disclosure Statement filed on March 9, 2001, the Examiner's attention is respectfully invited to review the accompanying form PTO-1449 along with a copy of the reference identified therein.

07/11/2003 HNL111 00000065 09803265 180.00 OP 01 FC:1806

This document was cited in an office action dated May 21, 2003 by the Korean Patent Office in the corresponding Korean patent application, Korean Patent Application No. 10-2001-0012464. This Korean application is also assigned to Kabushiki Kaisha Toshiba.

Pursuant to 37 C.F.R. § 1.97(d), this Information Disclosure Statement is being filed after receipt of the Final Office Action mailed May 21, 2003 and before payment of the Issue Fee. This document is accompanied by our check number 027282 in the amount of \$180.00, the fee set forth in 37 C.F.R. § 1.17(p).

This Information Disclosure Statement is not a representation that the documents cited herein are considered most pertinent, or that a search has been undertaken, or that the cited documents are indeed prior art. The Examiner is respectfully invited to undertake an independent search.

Applicants respectfully request that the Examiner consider and make of record the document cited herein and that a copy of Form PTO-1499, appropriately initialed by the Examiner, be returned to Applicants' attorney.

Applicants' undersigned attorney hereby certifies pursuant to 37 C.F.R. § 1.97(e) that each item of information contained in this Information Disclosure Statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the Information Disclosure Statement.

It is believed that no additional fee besides the \$180.00 is due, however, the Commissioner is hereby authorized to charge any additionally required fee or credit any overpayment therein to Deposit Account No. 50-0320.

Respectfully submitted,

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